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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/792,323	03/03/2004	Lawrence C. Lei	AMAT/5191C1/ISM/CORE/MCVD 4370	
44257 PATTERSON	7590 08/24/2007 & SHERIDAN I I P		EXAMINER	
PATTERSON & SHERIDAN, LLP 3040 POST OAK BOULEVARD, SUITE 1500			PAIK, SANG YEOP	
HOUSTON, TX 77056			ART UNIT	PAPER NUMBER
			3742	
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			MAIL DATE	DELIVERY MODE
	•		08/24/2007	PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

•	Application No.	Applicant(s)				
·	10/792,323	LEI, LAWRENCE C.				
Office Action Summary	Examiner	Art Unit				
	Sang Y. Paik	3742				
The MAILING DATE of this communication appeariod for Reply	ppears on the cover sheet with	the correspondence address				
A SHORTENED STATUTORY PERIOD FOR REP WHICHEVER IS LONGER, FROM THE MAILING - Extensions of time may be available under the provisions of 37 CFR after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory perioraliure to reply within the set or extended period for reply will, by state Any reply received by the Office later than three months after the mail earned patent term adjustment. See 37 CFR 1.704(b).	DATE OF THIS COMMUNICA 1.136(a). In no event, however, may a reply of will apply and will expire SIX (6) MONTH: ute, cause the application to become ABAN	TION. y be timely filed S from the mailing date of this communication. DONED (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on						
2a) ☐ This action is FINAL . 2b) ☑ Th						
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is						
closed in accordance with the practice under	r Ex parte Quayle, 1935 C.D. 1	1, 453 O.G. 213.				
Disposition of Claims						
4)⊠ Claim(s) <u>22-27,29-34 and 36-38</u> is/are pendi	ing in the application.					
4a) Of the above claim(s) is/are withdrawn from consideration.						
5) Claim(s) is/are allowed.						
6)⊠ Claim(s) <u>22-27,29-34 and 36-38</u> is/are rejected.						
7) Claim(s) is/are objected to.	.,					
8) Claim(s) are subject to restriction and	/or election requirement.					
Application Papers						
9) The specification is objected to by the Exami	ner.					
10)☐ The drawing(s) filed on is/are: a)☐ ad	ccepted or b) objected to by	the Examiner.				
Applicant may not request that any objection to the	• , ,					
Replacement drawing sheet(s) including the corre						
11)☐ The oath or declaration is objected to by the	Examiner. Note the attached C	Office Action or form PTO-152.				
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreig	gn priority under 35 U.S.C. § 1	19(a)-(d) or (f).				
a) ☐ All b) ☐ Some * c) ☐ None of:						
 Certified copies of the priority docume 	nts have been received.					
2. Certified copies of the priority docume	• •					
3. Copies of the certified copies of the pr	· ·	ceived in this National Stage				
application from the International Bure	, , , , , , , , , , , , , , , , , , , ,	anivad				
* See the attached detailed Office action for a li	st of the certified copies not re-	ceiveu.				
Attachment(s)						
1) Notice of References Cited (PTO-892)		nmary (PTO-413)				
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)		Mail Date rmal Patent Application				
Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date	6) Other:					

DETAILED ACTION

Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 22-27 and 29-31 are rejected under 35 U.S.C. 103(a) as being unpatentable over Onoe et al (US 6,270,839) or Suntola et al (US 4,389,973) in view of Arnold et al (US 5,224,202) or Horsky (US 6,452,338).

Once shows the apparatus for vaporizing a solid precursor claimed including a housing with at least two spaced surfaces such as the stainless steal mesh or wires with a solid precursor applied thereto, a heating member in thermal communication with the two surfaces and the housing (also see Figure 1), and an outlet that is connected to a growth chamber of a CVD apparatus. Suntola also shows the apparatus claimed including a housing with a carrier gas inlet, an outlet, at least two surfaces containing a solid precursor spaced to allow passage of the carrier gas therebetween, a heating member or source in thermal communication such as in thermal conduction for heating the wall of the housing and the at least two surfaces. Suntola also shows that heating element (56) can be provide with the precursor applied or contained surface

But, Once and Suntola do not show the heating member contained within the wall of the housing.

Arnold and Horsky show that it is well known in the art to provide a heating element contained within the wall of the housing to vaporize the materials contained therein. In view of

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Arnold or Horsky, it would have been obvious to one of ordinary skill in the art to adapt Oneo or Suntola with the heating members contained within the wall of the housing as an another effective alternative heating arrangement to heat the precursor contained in the housing.

With respect to claim 27, Suntola shows that it is known in the art that that the vaporized precursor is applied for the CVD or ALE (atomic layer Epitaxy) for the film deposition or growth. The applicant also describes in the application's background that such CVD and ALD depositions are well known in the art. Thus, it would have been obvious to one of ordinary skill to adapt the vaporization apparatus with the ALD deposition chamber or any other known chamber for the desired vaporized film depositions.

With respect to the recitation of solid precursors being tantalum or tungsten, it is noted that these recitations relate to the materials or articles worked upon by the apparatus, and they do not limit the apparatus claims. MPEP 2115.

3. Claims 32-34 and 36-38 are rejected under 35 U.S.C. 103(a) as being unpatentable over s as applied Onoe or Suntola in view of Arnold or Horsky to claims 22-27 and 29-31 above, and further in view of Gartner et al (US 4,947,790) or Loan et al (US 6,296,711).

Onoe or Suntola in view of Arnold or Horsky shows the apparatus claimed except for cone shaped surfaces.

Arnold shows the cone shaped surface, and Gartner and Loan are applied to further shows such cone shaped surface is well known in the art. Particularly, Gartner shows a solid precursor applied surface including a cone shaped surface as well as a linear and a U-shaped surface to hold the precursor and to allow the vaporization of the precursor upon heating. Gartner also teaches that solid precursor containing bed (13) is made of quartz which is a ceramic

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material. Loan also shows a precursor is applied to a cone shaped surface for the vaporization of such precursors. Loan also shows that it is also known in the art to provide a heater contained within the cone shaped surface to provide the vaporization heating.

In view of Gartner or Loan, it would have been obvious to one of ordinary skill in the art to adapt Onoe or Suntola, as modified by Arnold or Horsky, with the various shapes or surfaces including a cone-shaped surface as an alternative surface arrangement to conveniently support and hold a precursor, including a solid precursor, for a more effective vaporization of such precursor materials.

Response to Arguments

- 4. Applicant's arguments with respect to claims have been considered but are moot in view of the new ground(s) of rejection.
- 5. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Sang Y. Paik whose telephone number is 571-272-4783. The examiner can normally be reached on M-F (6:30-3:30) First Friday Off.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Tu Hoang can be reached on 571-272-4780. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Sang Y Paik
Primary Examiner
Art Unit 3742

syp